Sir:

Transmitted herewith for filing is the Patent Application of:

Inventor: SHIH WEI WANG, CHIA-DAR HSIEH

For: ENDURANCE IMPROVEMENT BY SIDEWALL NITRIDATION OF POLY FLOATING GATE FOR NONVOLATILE

MEMORY DEVICES USING SUBSTRATE OR DRAIN-SIDE ERASE SCHEME

Enclosed are:					
<del></del> 1	awing(s) - formal.				
		aiwan Samicanduct	or Manufacturing Co.		
<del></del>	_	$\neg$			
An associate p	power of attorney	Applicant claims	s small entity status		
Request & Ce	rtification under 35 US	SC 122(b)(2)(b)(i)			
The filing fee has been	calculated as shown be	low:			
	(Col. 1)	(Col. 2)	OTHER THAN A	A SMALL ENTITY	
FOR:	NO. FILED	NO. EXTRA	RATE	FEE	
BASIC FEE				\$ 770.	
TOTAL CLAIMS	41 -20=	21	x 18 =	\$ 378.	
INDEP CLAIMS	4 -3=	1	x 86 =	\$ 86.	
			SUB TOTAL	\$ 1,234.	1
			ASSIGNMENT	\$40.	
			TOTAL	\$ 1,274.	
X Please charge my Deposit Account No. 19-0033 in the amount of \$ 1,274. A duplicate copy of this sheet is enclosed.					
The Commiss	sioner is hereby authori	zed to charge payme	ent of the following fees ass	ociated with this comm	nunication or credit any
overpayment	to Deposit Account No	o. 19-0033. A dupli	cate copy of this sheet is end	closed.	
X A	Any additional filing fee	es required under 37	CFR §1.16.		
X	Any patent application p	processing fees unde	er 37 CFR §1.17.		
			Respectfully submitted,		
			STEPHEN B. ACKERM		I
		EXPRE	SS MAIL CERTIFICATE		
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I hereby certify that this correspondence is being deposited with the United States Postal Service as Express Mail in an envelope addressed to Assistant Commissioner of Patents, Alexandria, VA, 22313-1450. Applicant and/or Attorney requests the date of deposit as the Filing Date.

Date of deposit Signature Date